



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants : Katsuyuki NAKADA et al.

Group Art Unit : 1756

Appln No. : 10/801,689

Examiner : K. DUDA

Filed : March 17, 2004

Confirmation No. : 1890

For : RESIST PATTERN FORMING METHOD AND RESIST PATTERN  
FORMING SYSTEM

**SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT**

Commissioner for Patents  
U.S. Patent and Trademark Office  
Customer Service Window, Mail Stop AMENDMENT  
Randolph Building  
401 Dulany Street  
Alexandria, VA 22314

Sir :

In accordance with the duty of disclosure under 37 C.F.R. §1.56 and §§1.97-1.98 and supplemental to the Information Disclosure Statements that were previously filed on March 3, 2006; November 22, 2005 and June 16, 2004, Applicants hereby bring to the attention of the Examiner a Japanese Office Action dated December 19, 2006, with respect to patent family member Japanese Patent Application No. 2003-073680, in which the following documents were cited:

- (1) Japanese Patent Publication No. JP 2002-319531 A, together with an English language Abstract and an English language computer-generated translation thereof and family member U.S. Patent No. 6,768,067;
- (2) Japanese Patent Publication No. JP 10-274854 A, together with an English language Abstract and an English language computer-generated translation thereof;

- (3) Japanese Patent Publication No. JP 3-042815 A, together with an English language Abstract and an English language partial translation thereof;
- (4) Japanese Patent Publication No. JP 2-106758 A, together with an English language Abstract and an English language partial translation thereof;
- (5) Japanese Patent Publication No. JP 11-297584 A, together with an English language Abstract and an English language computer-generated translation thereof;  
and
- (6) Japanese Patent Publication No. JP 2-264960 A, together with an English language Abstract and an English language partial translation thereof.

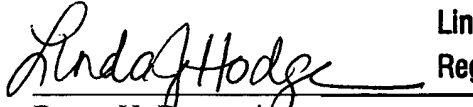
The relevance of these documents, as ascertained with respect to the Japanese claims by the Japanese Examiner, is set forth in the Japanese Office Action.

Applicants respectfully request that the Examiner consider the above material and cite the same. Copies of the above-noted documents are attached hereto, and are listed on an attached Form PTO-1449. Copies of the Japanese Office Action and an English language translation thereof are also attached hereto. The Examiner is requested to initial the appropriate spaces on the attached Form, and to return a copy of the completed Form to Applicants with the next official communication in the present application.

Applicants note that an Office Action on the merits has not issued in the present application, and thus no fee is believed necessary to ensure consideration of the submitted material.

Should the Examiner have any questions, the Examiner is invited to contact the undersigned at the below-listed telephone number.

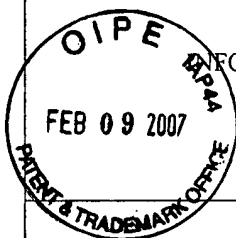
Respectfully Submitted,  
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Application No.  
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(Use several sheets if necessary)

Filing Date  
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Group  
1756[illegible]

		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES	NO
	2002	- 3 1 9 5 3 1	10/31/02	JAPAN			X	
	10	- 2 7 4 8 5 4	10/13/98	JAPAN			X	
	3	- 0 4 2 8 1 5	02/25/91	JAPAN				
	2	- 1 0 6 7 5 8	04/18/90	JAPAN				
	11	- 2 9 7 5 8 4	10/29/99	JAPAN			X	
	2	- 2 6 4 9 6 0	10/29/90	JAPAN				

		English Language Abstract of JP 2002-319531.
		English Language Abstract of JP 10-274854.
		English Language Abstract and English Language Partial Translation of JP 3-042815
		English Language Abstract and English Language Partial Translation of JP 2-106758.
		English Language Abstract of JP 11-297584.
		English Language Abstract and English Language Partial Translation of JP 2-264960.

DATE CONSIDERED

\*EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.